2SK360

Silicon N-Channel MOS FET

HITACHI

Application

VHF amplifier

Outline

MPAK

3
1. Gate
2. Drain
3. Source



2SK360

Absolute Maximum Ratings ($Ta = 25^{\circ}C$)

Item	Symbol	Ratings	Unit
Drain to source voltage	V _{DSX} *1	20	V
Gate to source voltage	V _{GSS}	±5	V
Drain current	I _D	30	mA
Gate current	I _G	±1	mA
Channel power dissipation	Pch	150	mW
Channel temperature	Tch	150	°C
Storage temperature	Tstg	-55 to +150	°C

Note: 1. $V_{GS} = -4 \text{ V}$

Electrical Characteristics ($Ta = 25^{\circ}C$)

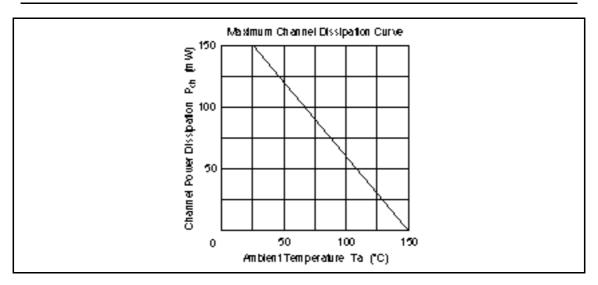
Item	Symbol	Min	Тур	Max	Unit	Test conditions
Drain to source breakdown voltage	$V_{(BR)DSX}$	20	_	_	V	$I_D = 100 \ \mu A, \ V_{GS} = -4 \ V$
Gate cutoff current	I _{GSS}	_	_	±20	nA	$V_{GS} = \pm 5 \text{ V}, V_{DS} = 0$
Drain current	I _{DSS} *1	4	_	12	mA	$V_{DS} = 10 \text{ V}, V_{GS} = 0$
Gate to source cutoff voltage	$V_{\text{GS(off)}}$	0	_	-2.0	V	$V_{DS} = 10 \text{ V}, I_{D} = 10 \mu\text{A}$
Forward transfer admittance	y _{fs}	8	14	_	mS	$V_{DS} = 10 \text{ V}, V_{GS} = 0,$ f = 1 kHz
Input capacitance	Ciss	_	2.5	_	pF	$V_{DS} = 10 \text{ V}, V_{GS} = 0,$ f = 1 MHz
Output capacitance	Coss	_	1.6	_	pF	_
Reverse transfer capacitance	Crss	_	0.03	_	pF	_
Power gain	PG	_	30	_	dB	$V_{DS} = 10 \text{ V}, V_{GS} = 0,$ f = 100 MHz
Noise figure	NF	_	2.0	_	dB	_

Note: 1. The 2SK360 is grouped by I_{DSS} as follows.

Grade	D	E	F
Mark	IGD	IGE	IGF
I _{DSS}	4 to 8	6 to 10	8 to 12

See characteristic curves of 2SK359.

2SK360



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